

M2D-1200-0030

Silicon Carbide Power MOSFET Bare Die

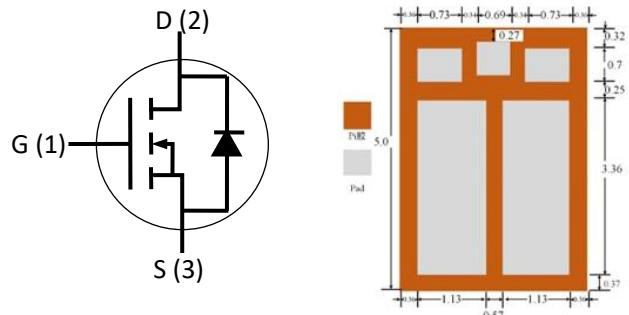
N-Channel Enhancement Mode

Features

- High Blocking Voltage with Low On-Resistance
- High-Speed Switching with Low Capacitances
- Easy to Parallel and Simple to Drive
- Avalanche Ruggedness
- Halogen Free, RoHS Compliant

- Pulsed Power applications

Package



Benefits

- Higher System Efficiency
- Reduced Cooling Requirements
- Increased Power Density
- Increased System Switching Frequency

Applications

- Solar Inverters
- Switch Mode Power Supplies
- High Voltage DC/DC Converters
- Battery Chargers
- Motor Drives

Part Number	Die Size(mm)
M2D-1200-0030	3.65*5.01

Maximum Ratings ($T_c = 25^\circ\text{C}$ unless otherwise specified)

Symbol	Parameter	Value	Unit	Test Conditions	Note
$V_{DS\max}$	Drain - Source Voltage	1200	V	$V_{GS}=0\text{V}$, $I_D=100\mu\text{A}$	
$V_{GS\max}$	Gate - Source Voltage	-10/+22	V	Absolute maximum values	
V_{GSop}	Gate - Source Voltage	-6/+18	V	Recommended operational values	
I_D	Continuous Drain Current	76 68	A	$V_{GS}=18\text{V}$, $T_c=25^\circ\text{C}$ $V_{GS}=18\text{V}$, $T_c=100^\circ\text{C}$	
T_J , T_{stg}	Operating Junction and Storage Temperature	-55 to +175	°C		

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Electrical Characteristics

Symbol	Parameter	Min.	Typ.	Max.	Unit	Test Conditions	Note
$V_{(BR)DSS}$	Drain-Source Breakdown Voltage	1200			V	$V_{GS}=0V, I_D=100\mu A$	
$V_{GS(th)}$	Gate Threshold Voltage	2.2	3.2	4.5	V	$V_{GS} = V_{DS}, I_{DS}=9.5mA, T_c=25^\circ C$	
			2.2			$V_{GS} = V_{DS}, I_{DS}=9.5mA, T_c=175^\circ C$	
I_{DSS}	Zero Gate Voltage Drain Current		5	50	μA	$V_{DS}= 1200V, V_{GS}=0V$	
I_{GSS+}	Gate-Source Leakage Current			100	nA	$V_{GS}=18V, V_{DS}= 0V$	
I_{GSS-}	Gate-Source Leakage Current			100	nA	$V_{GS}=-6V, V_{DS}= 0V$	
$R_{DS(on)}$	Drain-Source on-state Resistance	20	30	40	$m\Omega$	$V_{GS}=18V, I_D=40A, T_c=25^\circ C$	
			48			$V_{GS}=18V, I_D=40A, T_c=175^\circ C$	
g_{fs}	Transconductance		25		S	$V_{GS} = 18 V, I_D = 40A, T_J = 25^\circ C$	
			15		S	$V_{GS} = 18 V, I_D = 40A, T_J = 175^\circ C$	
C_{iss}	Input Capacitance		2940		pF	$V_{GS}=0V, V_{DS}=1000 V, f=1MHz$ $V_{AC}=25 mV$	
C_{oss}	Output Capacitance		129				
C_{rss}	Reverse Transfer Capacitance		15				
E_{ON}	Turn-On Switching Energy		1.278		mJ	$V_{DS}=800V, V_{GS}=-5/18V, I_D= 40 A,$	
E_{OFF}	Turn-Off Switching Energy		0.154				
$t_{d(on)}$	Turn-On Delay Time		14				
t_r	Rise Time		32		ns	$V_{DS}=800V, V_{GS}=-5/18 V$ $I_D = 40A,$	
$t_{d(off)}$	Turn-Off Delay Time		32				
t_f	Fall Time		12				
$R_{G(int)}$	Internal Gate Resistance		2.2		Ω	$f=1 MHz, V_{AC}=25mV$	
Q_{gs}	Gate to Source Charge		34		nC	$V_{DS}=800V, V_{GS}=-5/18 V$ $I_D = 40A$	
Q_{gd}	Gate to Drain Charge		35				
Q_g	Total Gate Charge		138				

Reverse Diode Characteristics

Symbol	Parameter	Typ.	Max.	Unit	Test Conditions	Note
V_{SD}	Diode Forward Voltage	4.9		V	$V_{GS} = -4V, I_{SD} = 20 A, T_J = 25^\circ C$	
		4.4		V	$V_{GS} = -5V, I_{SD} = 25 A, T_J = 175^\circ C$	
I_s	Continuous Diode Forward Current	68		A	$T_c = 25^\circ C$	

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Mechanical Parameters

Parameter	Typ.	Unit
Die Size	3.65 x 5.01	mm
Source Pad Size (power & signal)	1.13 x 3.36 & 0.73 x 0.7	mm
Gate Pad Size	0.69 x 0.7	mm
Thickness	150 ± 10%	μm
Wafer Size	150	mm
Top Side Metalization (AlCu)	5	μm
Bottom Side Metalization (Ti-Ni-Ag)	1.55	μm

